

Reaction of Carbonyl Compounds with Trialkylsilyl Phenylselenide and Tributylstannyl Hydride under Radical Conditions

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A novel method for the hydrosilylation of carbonyl compounds has been developed. When carbonyl compounds were allowed to react with trimethylsilyl phenylselenide and tributylstannyl hydride in the presence of a catalytic amount of AIBN as the radical initiator, hydrosilylation of the carbonyl compounds efficiently proceeded to give the corresponding silvl ethers in moderate to good yields. In the absence of carbonyl compounds, the triethylsilyl hydride was obtained by the reaction of PhSeSiEt₃ with Bu₃SnH. Although the tributylgermyl phenylselenide instead of PhSeSiMe₃ was treated with tributylstannyl hydride in the presence of a benzaldehyde under radical conditions, hydrogermylated product was not obtained and tributylgermyl hydride was mainly formed.

Clive first reported that the reaction of an organoselenide (RSePh) with tributylstannyl hydride under radical conditions was an efficient generation method of carbon radicals.1 Since then, such generated carbon radicals have found widespread use in various transformations.² For the generation method using organoselenium compounds as a radical precursor, the reaction pathway involved the S_H2 reaction of tributylstannyl radical with organoselenium compounds on the selenium atom was proposed.³ From this background, it is expected that the reaction of organoselenium compounds having the selenium-heteroatom bond with tributylstannyl hydride in the presence of a radical initiator such as AIBN would become an excellent generation method for the various heteroatom radical species.

The development of new methods for the generation of organosilicon radicals such as the trialkylsilyl radical (R₃Si[•]) and the utilization of these radicals in organic synthesis is one of challenging problems in organic chemistry.⁴ Up to now, some organosilicon radical generation methods have been reported.^{5,6} However, the efficient utilization of these silicon radicals in organic synthesis is very limited because the recombination to

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the disilane or the disproportination to the trialkylsilane of the silyl radicals easily occurred during these preparation methods for the silyl radicals.¹² Therefore, new efficient and convenient generation methods for the trialkylsilyl radical are desired.

We then examined the preparation of the trialkyl silyl radical by the reaction of a small excess amount of

(6) Substitution of silyl radicals by the introduction of bulky substituents such as *tert*-butyl,⁷ mesityl,⁸ 3,5-di-*tert*-butylphenyl,⁹ trimethylsilyl,¹⁰ and other groups¹¹ has been attempted. (7) Jackson, R. A.; Weston, H. *J. Organomet. Chem.* **1984**, *277*, 13.

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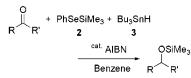
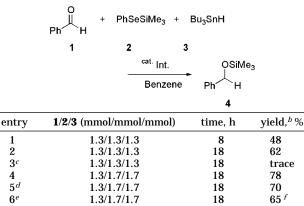


TABLE 1. Reaction of Benzaldehyde (1) withPhSeSiMe3 (2) and Bu3SnH (3) under Various ReactionConditions^a



^{*a*} Reaction conditions: in benzene (5 mL) at 80 °C. ^{*b*} GC yield. ^{*c*} In the absence of AIBN. ^{*d*} AMVN (bisdiazaisovaleronitrile) instead of AIBN was used as a radical initiator at 60 °C. ^{*e*} PhSeSiEt₃ instead of PhSeSiMe₃ was used as organoselenium compound. ^{*f*} The yield of triethylsilyl benzyl ether.

PhSeSiMe₃ with tributylstannyl hydride under radical conditions in the presence of carbonyl compounds as a trapping agent of the silyl radical and found that the hydrosilylation of the carbonyl compounds efficiently proceeded to give the corresponding trimethylsilyl ethers in moderate to good yields (Scheme 1).¹³ The full results of the reaction of trialkylsilyl or trialkylgermyl phenylselenide with tributylstannyl hydride in the presence of carbonyl compounds under radical conditions are disclosed in this paper.

The treatment of benzaldehyde (1) with trimethylsilyl phenylselenide (PhSeSiMe₃) (2) and tributylstannyl hydride (3) was carried out in the presence of a radical initiator, and the results are shown in Table 1. When 1 was allowed to react with 2 and 3 in the presence of a catalytic amount of AIBN at 80 °C for 8 h, the hydrosilylation of 1 efficiently proceeded to give the trimethylsilylbenzyl ether (4) in 48% yield (entry 1). The extended reaction time (18 h) caused an increase in the yield of silyl ether (entry 2). The yield of 4 was improved by using a small excess amount of **2** (1.3 equiv) and **3** (1.3 equiv), and 4 was obtained in 78% yield (entry 3). In the absence of AIBN, the reaction did not proceed at all (entry 3). When AMVN (azobisisovaleronitrile) instead of AIBN was used as the radical initiator, the hydrosilylation of 1 smoothly proceeded at a lower reaction temperature (entry 5). The hydrosilylation of 1 with triethylsilylphenylselenide and 3 in the presence of AIBN also proceeded to give the triethylsilylbenzyl ether in 65% yield (entry 6).

To know the scope and limitations of the hydrosilylation method of carbonyl compounds with **2** and **3**, various

TABLE 2.	Hydrosilylation of Aromatic Aldehydes with
	and Bu ₃ SnH in the Presence of a Catalytic
Amount of	AIBN ^a

entry	carbonyl Compound	yield/% ^t
	СНО	
1	X = H	78
2	= 2-Me	65
3	= 3-Me	77
4	= 4-Me	80
5	= 4-MeO	85
6 ^c	= 4-NO ₂	12
7 ^c	= 4-CI	74
8 ^c	= 4-Br	45
9 ^c	СНО	81
10 [°]	СНО	86

^{*a*} Reaction conditions: carbonyl compound (1.3 mmol), PhSeSi-Me₃ (1.7 mmol), Bu₃SnH (1.7 mmol), AIBN (0.13 mmol), and benzene (5 mL) at 80 °C for 18 h. ^{*b*} GC yield. ^{*c*} For 48 h.

aromatic aldehydes were first allowed to react with a small excess amount of 2 and 3 in the presence of a catalytic of AIBN at 80 °C (Table 2). For the 3- and 4-methylbenzaldehydes, the corresponding silvl ethers were obtained in 77 and 80% yields, respectively (entries 3 and 4). In the case of 2-methylbenzaldehyde, the yield of the silvl ether was slightly decreased (entry 2). Similarly, 4-methoxybenzaldehyde was hydrosilylated by the PhSeSiMe₃/Bu₃SnH/AIBN system giving 4-methoxybenzyltrimethylsilyl ether in 85% yield (entry 5). For the reaction of 4-nitrobenzaldehyde, the yield of the silvl ether was markedly decreased due to the formation of complex byproducts (entry 6). When 4-chlorobenzaldehyde was reacted with PhSeSiMe₃ and Bu₃SnH under the same reaction conditions as for the benzaldehyde, the yield of the product was moderate (48%); however, the product yield was improved by extending the reaction time (48 h) (entry 7). For the 4-bromobenzaldehyde, benzyl trimethylsilyl ether (35%), which is the debromination product, was formed as a byproduct (entry 8). The hydrosilylation of the 1- and 2-naphthylaldehydes also smoothly proceeded to afford the corresponding silyl ethers in good yields (entries 9 and 10). Table 3 shows the results of the treatment of aromatic ketones with PhSeSiMe₃ and Bu₃SnH. Similarly, various silyl ethers were synthesized by the reaction of aromatic ketones with PhSeSiMe₃ and Bu₃SnH in the presence of a catalytic amount of AIBN in moderate yields. Aliphatic aldehydes or ketones were treated with PhSeSiMe3 and Bu3SnH under radical conditions, and the results are shown in Scheme 2. For the reaction of octanal, 2-ethylhexanal, and cyclohexanecarboaldehyde, trimethylsilyl ethers were

⁽¹³⁾ For recent reviews of the radical-mediated reduction of carbonyl compounds by using silicon reagents. See ref 4f.

vield/%b carbonyl Compound entry 1 56 R = H2 60 3° 71 **4**° 46 5° 56 60 48

 TABLE 3. Hydrosilylation of Aromatic Ketones Using

 PhSeSiMe₃ and Bu₃SnH in the Presence of a Catalytic

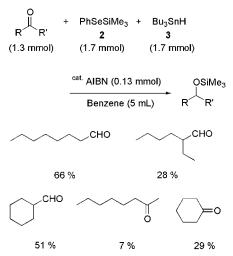
 Amount of AIBN^a

^{*a*} Reaction conditions: carbonyl compound (1.3 mmol), PhSeSi-Me₃ (1.7 mmol), Bu₃SnH (1.7 mmol), AIBN (0.13 mmol), and benzene (5 mL) at 80 °C for 18 h. ^{*b*} GC yield. ^{*c*} For 48 h.

64

SCHEME 2

7



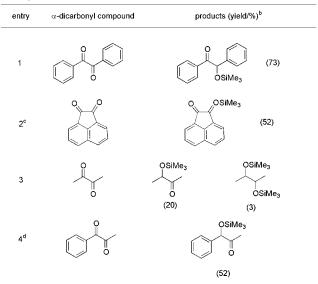
obtained in 66, 28, and 51% yields, respectively. For the aliphatic ketones, the yields of the silyl ethers were lower than those of the aromatic ketones.¹⁴

Next, α -dicarbonyl compounds were treated with a small excess amount of PhSeSiMe₃ and Bu₃SnH in the presence of a catalytic amount of AIBN (Table 4). The

 TABLE 4.
 Hydrosilylation of Dicarbonyl Compounds

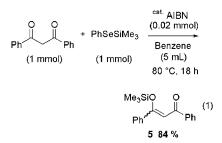
 Using PhSeSiMe3 and Bu3SnH in the Presence of a

 Catalytic Amount of AIBN^a



 a Reaction conditions: carbonyl compound (0.5 mmol), PhSeSi-Me_3 (1.2 mmol), Bu_3SnH (1.2 mmol), AIBN (0.05 mmol), and benzene (5 mL) at 80 °C for 18 h. b GC yield. c For 24 h. d Phenyl(1-trimethylsiloxy)ethyl ketone was formed in 16% yield.

monohydrosilylation of benzil and acenaphthenequinone smoothly proceeded to give the corresponding monohydrosilylated products in moderate yield (entries 1 and 2). Although the reaction of benzil with an excess amount of PhSeSiMe₃ and Bu₃SnH (5/5 equiv) was carried out, the dihydrosilylated product was not formed. In contrast to the reaction of diaryl ketone, for the reaction of 2,3butanedione, a mixture of mono- and dihydrosilylated products was formed (entry 3). Upon hydrosilylation of 1-phenyl-1,2-propanedione using this system, the hydrosilvlation of the carbonyl group adjacent to the aromatic ring predominantly proceeded to give the methyl(trimethylsiloxy)benzyl ketone in 52% yield with the formation of phenyl(1-trimethylsiloxy)ethyl ketone (16%) (entry 4). On the other hand, for the β -dicarbonyl compound, the β -siloxy- α , β -unsaturated ketone derivative (5) was formed in 84% yield (eq 1).¹⁵

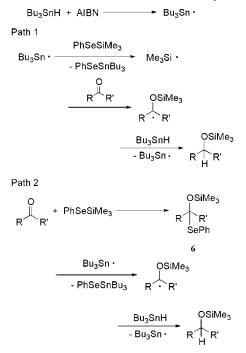


Although we cannot explain the reaction pathway of the hydrosilylation of the carbonyl compounds using the PhSeSiMe₃/Bu₃SnH/AIBN system in detail, two possible reaction pathways were proposed for the reaction (Scheme 3). One is the addition of the trimethylsilyl radical, which was generated in situ by the reaction of PhSeSiMe₃ with

⁽¹⁴⁾ The absolute rate constants for the reaction of triethylsilyl radical with some carbonyl compounds are reported. The ease of addition of Et₃Si radical was found to decrease in order benzaldehyde > alkyl aryl ketone > alkyl aldehyde > acyclic dialkyl ketone; see: (a) Chatgilaloglu, C.; Irgolg, K. V.; Scaiano, J. J. Am. Chem. Soc. **1982**, *104*, 5119. (b) Cooper, J.; Hudson, A.; Jackson, R. A. J. Chem. Soc., Perkin Trans. 2 **1973**, 1933.

⁽¹⁵⁾ Liotta, D.; Petty, P. B.; Johnston, J.; Zima, G. *Tetrahedron Lett.* **1978**, 5091.

SCHEME 3. Plausible Reaction Pathways



the tributylstannyl radical, to the carbonyl compound and subsequent S_H2 reaction with Bu_3SnH to form the silyl ether (path 1). It was already reported that the silylselenation of carbonyl compounds with PhSeSiMe₃ was promoted by a Lewis¹⁵ acid or I_2^{16} giving α -siloxyphenylselenides (**6**) in good yields. From this result, another reaction pathway including the silylselenation of the carbonyl compounds with PhSeSiMe₃ and the dephenylselenation by the tributylstannyl radical followed by the S_H2 reaction with Bu_3SnH was proposed (path 2). To clarify this reaction pathway, although benzaldehyde was allowed to react with PhSeSiMe₃ in the absence of Bu_3SnH , the silylselenated product was not formed and the benzaldehyde (97%) was recovered (eq 2). Further-

more, when $PhSeSiEt_3$ was treated with Bu_3SnH in the absence of a carbonyl compound under the radical conditions (in the presence of a catalytic amount of AIBN), the triethylsilyl hydride was obtained in 43% yield (eq 3). From these results, it appears reasonable to assume the generation pathway of the silyl radical as an intermediate (path 1).

	^{cat.} AIBN (0.1 mmol)		
PhSeSiEt ₃ + Bu ₃ SnH ⁻ (1 mmol) (1 mmol)	Benzene (5 mL) 80 °C for 18 h	Et ₃ SiH 43 %	(3)

When an organoselenium compound having the selenium-germanium bond is reacted with tributylstannyl hydride in the presence of AIBN as the radical initiator, it is expected that the compound would become an excellent precursor for the trialkylgermyl radical species. In fact, the treatment of $PhSeGeBu_3$ with Bu_3SnH in the presence of a catalytic amount of AIBN gave tributylgermyl hydride in 80% yield (eq 4). Although the reaction

was carried out in the presence of benzaldehyde, in contrast to that of the trialkylsilyl phenylselenide, the hydrogermylated product was not formed and the trialkylgermyl hydride was mainly obtained in 56% yield (eq 5).

PhCHO + PhSeBeBu₃ + Bu₃SnH
(0.2 mmol) (0.26 mmol) (0.39 mmol)

$$\xrightarrow{\text{cat. AIBN}}_{(0.02 \text{ mmol})}$$
 Bu₃GeH + PhCH₂OH (5)
Benzene
(5 mL) 56 % 22 %
80 °C for 18 h

In summary, we have successfully explored an efficient synthetic method for silyl ethers by the hydrosilylation of carbonyl compounds by the PhSeSiMe₃/Bu₃SnH/AIBN system. In this reaction, the in situ generation of a silyl radical by the reaction of organoselenium compounds having Se–Si bonds with the tributyl stannyl radical was proposed.

Experimental Section

¹H and ¹³C NMR spectra were recorded on 400 and 99.5 MHz spectrometers in CDCl₃ as the solvent with tetramethylsilane as the internal standard. FT-IR spectra were recorded using a KBr disk. Mass spectra were measured on a GC mass spectrometer. Gas chromatography was carried out on a Shimadzu GC-14A equipped with a flame-ionization detector using a capillary column (Hicap-CBP-1-S25-025, 0.25 mm × 25 m). The carbonyl compounds, Bu₃SnH, and benzene, were purified by the usual methods before use. PhSeSiMe₃ was prepared by the literature method.¹⁷ Tributylgermyl phenylselenide was synthesized by the reaction of tributylgermyl chloride with lithium phenylselenoate generated in situ by the treatment of PhLi and elemental selenium. 1-Phenyl-1,2-propanedione was synthesized by the oxidation of propiophenone with SeO₂.¹⁸

General Procedure for the Hydrosilylation of Carbonyl Compounds with PhSeSiMe₃ and Bu₃SnH in the Presence of a Catalytic Amount of AIBN. A benzene (5 mL) solution of the carbonyl compound (1.3 mmol), PhSeSiMe₃ (400 mg, 1.7 mmol), Bu₃SnH (510 mg, 1.7 mmol), and AIBN (22 mg, 0.13 mmol) was stirred at 80 °C for 18–72 h under a nitrogen atmosphere. After the reaction was completed, H₂O was added to the reaction mixture and extracted with Et₂O (×3). The combined organic layers were dried over MgSO₄ and removed under reduced pressure. The remaining solution was purified by HPLC to give the corresponding silyl ether. The structures of the products were determined by ¹H and ¹³C NMR, IR, and MS.

General Procedure for the Hydrosilylation of α -Dicarbonyl Compounds with PhSeSiMe₃ and Bu₃SnH in the Presence of a Catalytic Amount of AIBN. A benzene

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(5 mL) solution of the α -dicarbonyl compound (0.5 mmol), PhSeSiMe₃ (270 mg, 1.2 mmol), Bu₃SnH (350 mg, 1.2 mmol), and AIBN (9 mg, 0.05 mmol) was stirred at 80 °C for 48 h under a nitrogen atmosphere. After the reaction was completed, H₂O was added to the reaction mixture and extracted with Et₂O (×3). The combined organic layers were dried over MgSO₄ and removed under reduced pressure. The remaining solution was purified by HPLC to give the corresponding silyl ether. The structures of the products were determined by ¹H and ¹³C NMR, IR, and MS.

Reaction of PhSeSiMe₃ with Bu₃SnH in the Presence of a Catalytic Amount of AIBN. A benzene (5 mL) solution of PhSeSiMe₃ (240 mg, 1.0 mmol), Bu₃SnH (291 mg, 1.0 mmol), and AIBN (22 mg, 0.13 mmol) was stirred at 80 °C for 18 h under a nitrogen atmosphere. After the reaction was completed, H₂O was added to the reaction mixture and extracted with Et₂O (×3). The combined organic layers were dried over MgSO₄ and removed under reduced pressure. The remaining solution was purified by HPLC to give the corresponding silyl ether. The structures of product were determined by ¹H and ¹³C NMR, IR, and MS.

Reaction of PhSeGeBu₃ with Bu₃SnH in the Presence of a Catalytic Amount of AIBN. A benzene (5 mL) solution of PhSeGeBu₃ (104 mg, 0.26 mmol), Bu₃SnH (113 mg, 0.39 mmol), and AIBN (4 mg, 0.02 mmol) was stirred at 80 °C for 18 h under a nitrogen atmosphere. After the reaction was completed, H₂O was added to the reaction mixture and extracted with Et₂O (×3). The combined organic layers were dried over MgSO₄ and removed under reduced pressure. The remaining solution was purified by HPLC to give the mixture of benzyl alcohol and tributylgermyl hydride. The structures of the products were determined by 1 H and 13 C NMR, IR, and MS.

Reaction of Benzaldehyde with PhSeGeBu₃ and Bu₃SnH in the Presence of a Catalytic Amount of AIBN. A benzene (5 mL) solution of benzaldehyde (21 mg, 0.2 mmol), PhSeGeBu₃ (104 mg, 0.26 mmol), Bu₃SnH (113 mg, 0.39 mmol), and AIBN (4 mg, 0.02 mmol) was stirred at 80 °C for 18 h under a nitrogen atmosphere. After the reaction was complete, H₂O was added to the reaction mixture and extracted with Et₂O (×3). The combined organic layers were dried over MgSO₄ and removed under reduced pressure. The remaining solution was purified by HPLC to give the mixture of benzyl alcohol and tributylgermyl hydride. The structures of the products were determined by ¹H and ¹³C NMR, IR, and MS.

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Supporting Information Available: NMR spectra of obtained compounds. This material is available free of charge via the Internet at http://pubs.acs.org.

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